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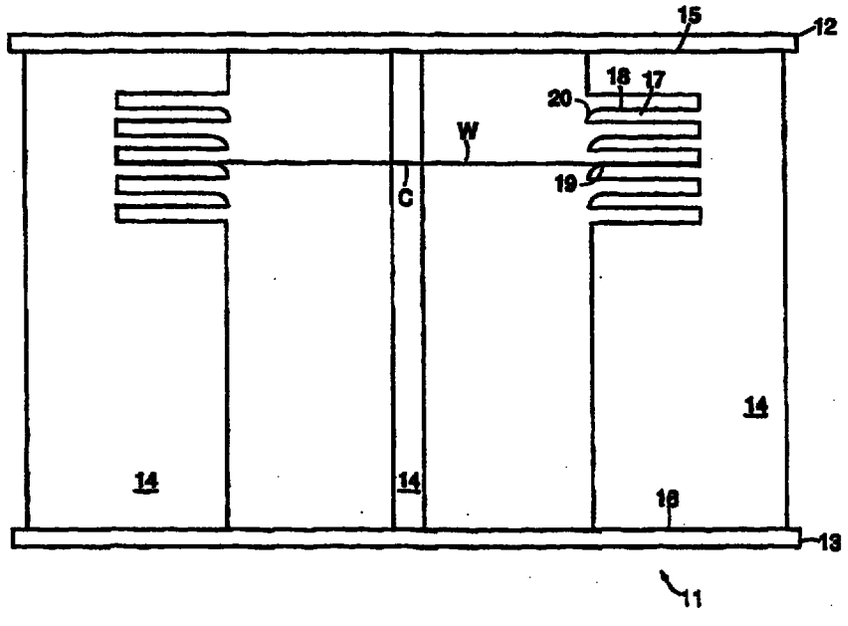
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(54) Title: SLIP FREE VERTICAL RACK DESIGN HAVING ROUNDED HORIZONTAL ARMS



(57) Abstract

The invention relates to a vertical rack for semiconductor wafer processing having strictly horizontally disposed arms wherein each arm has a rounded tip and a smooth (Ra < 1 μm) upper surface.